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Photocatalytic formation of a gas permeable layer selectively deposited on supported metal nanoparticles for sintering-resistant thermal catalysis†

Ayato Takabayashi,^a Fuminao Kishimoto,^{id}^a Hiroto Tsuchiya,^b Hitoshi Mikami^b and Kazuhiro Takanabe^{id}^{*a}

Nanoparticle aggregation of supported metal catalysts at high temperatures is a serious problem that causes a drop in catalytic performance. This study investigates the protection of metal nanoparticles from sintering by selectively forming nanoscale SiO₂ shells on Pd supported on TiO₂ by ultraviolet (UV) light irradiation. The proton-coupled reduction reaction increases the local pH around Pd nanoparticles, resulting in hydrolysis of tetraethoxyorthosilicate (TEOS) in only the vicinity of the metal. An apparent quantum efficiency of only 0.6% is obtained for the Pd/TiO₂ catalyst in H₂ evolution from ethanol-containing water under 370 nm excitation light. Therefore, the pH of raw slurry solution should be precisely controlled to that slightly below the threshold value for the TEOS hydrolysis reaction before the photodeposition. Transmission electron microscopy (TEM) and energy dispersive X-ray spectroscopy (EDX) clearly show that the particle size of the Pd nanoparticles (~40 nm) with the SiO₂ shell (~20 nm) was almost unchanged by the high-temperature treatment at 900 °C in air, suggesting that the SiO₂ shell prevented thermal aggregation of Pd nanoparticles. The Pd/TiO₂ without SiO₂ shell decoration exhibited a drop in the number of active sites, which was likely due to aggregation of the Pd catalysts. However, the number of active sites on the Pd@SiO₂/TiO₂ catalyst was maintained even after the catalyst was calcined at 900 °C. Consequently, the Pd@SiO₂/TiO₂ catalyst maintained its catalytic performance for simulated exhaust gas purification even after treatment at 900 °C. This study presents a methodology to produce sintering-tolerant supported metal nanoparticles using the photocatalytic gas permeable layer fabrication method.

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Introduction

An exhaust-gas purification system for automobiles uses an excessive amount of noble metals due to aggregation of the supported metal catalysts under harsh conditions, such as high-temperature hydrothermal conditions.^{1,2} Aggregation is a phenomenon in which highly dispersed nanoparticles fuse on support materials at high temperature, resulting in particles with a large diameter and low dispersion.^{3,4} The aggregation is typically induced by increased diffusion coefficients due to temperature beyond the Tammann temperature,⁵ nanosizing of particles⁶ (Ostwald ripening⁷), or direct particle migration and coalescence.⁸ Suppressing the sintering could allow for high reactivity to be maintained for the exhaust-gas purification

reaction, which could minimize the amount of noble metals (Rh, Pd, and Pt) used in the system, thus reducing the system cost and mitigating security risks related to the rare metals.

Many studies have proposed ways to avoid the aggregation of metal particles on a support,⁹ such as the development of a series of “super intelligent” catalysts,¹⁰ enhanced metal-support interactions,^{11–13} and coating metal nanoparticles with thin metal oxide layers.^{14–20} However, the aggregation of the supported Pd nanoparticles under high-temperature treatment is complicated, and redispersion and sintering can occur during calcination in the presence of oxygen.^{21–23} Two-dimensional surface Pd oxides during oxidation have been considered to be responsible for the redispersion of the Pd nanoparticles. Because the redispersion temperature depends on the Pd particle size, there is a very complex trade-off between the redispersion and aggregation of Pd nanoparticles. Such complex physicochemical phenomena lead us to fabricate an ensured protection layer on nanoparticles by encapsulation.²⁴

Indeed, while there are many reports on the encapsulation of metal nanoparticles by metal oxide protection layers, most of them demonstrated self-assembly of metal alkoxides on

^aDepartment of Chemical System Engineering, School of Engineering, The University of Tokyo, 7-3-1 Hongo, Bunkyo-ku, Tokyo, 113-8656, Japan. E-mail: takanabe@chemsys.t.u-tokyo.ac.jp

^bHonda R&D Co., Ltd., 4630 Shimotakanezawa, Haga-machi, Hagagun, Tochigi 321-3393, Japan

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colloidal metal nanoparticles.^{25–31} The assembly of metal alkoxide precursors with a structure directing agent (SDA) can be induced by surfactant molecules or a microemulsion environment around the metal nanoparticles, resulting in the formation of gas-permeable metal oxide layers. Although these synthetic methods are well established in terms of materials chemistry, they are not suitable for industrial catalytic applications that require robust supports. Nevertheless, there are very limited examples of fabricating metal oxide protective layers on supported metal nanoparticle catalysts. Stair *et al.* developed a metal oxide decoration method on supported metal catalysts using atomic layer deposition (ALD).^{32,33} Appropriate thermal treatment of the encapsulated catalyst can induce gas permeability of the metal oxide layers by the formation of cracks. However, large-scale manufacturing processes using ALD have not yet been established due to the requirement of vacuum conditions and extraordinary devices. Although strong metal–support interaction (SMSI) under reducing conditions that can also induce spontaneous encapsulation of supported metal nanoparticles is well studied,^{34,35} the SMSI state is not stable during the oxidative exhaust-gas purification reaction.

In this study, we demonstrated a photocatalytic fabrication method of an ultrathin SiO₂ layer selectively decorated on already supported Pd metal nanoparticles to develop a sintering-resistant exhaust gas purification catalyst. The SiO₂ layer decoration was done using a slurry consisting of Pd/TiO₂ catalysts, tetraethylorthosilicate (TEOS) as a silica source, aqueous NaNO₃ as an electrolyte, and the tetramethylammonium cation (TMA⁺) as an SDA. Thermal decomposition of the SDA endows the SiO₂ layer with gas permeability, which enables the reactant exhaust gas components to get access to the Pd surface. This fabrication method is an application of our previous report on the decoration of a SiO₂ layer over the Pt/SrTiO₃ photocatalyst to develop efficient particulate photocatalysts for overall water splitting.³⁶ The role of the SiO₂ shell on Pt/SrTiO₃ is to function as a nano-membrane; H₂ generated inside the shell should escape through it, but O₂ generated outside cannot reach the Pt surface, preventing the reverse reaction of the overall water splitting. This reaction proceeded at close to room temperature in the liquid phase. The current paper investigates whether this nano-membrane selectively decorated on the supported metal particles can be applied to high-temperature exhaust gas purification. The physicochemical role of the SiO₂ layer in sintering-resistance of supported Pd nanoparticles was investigated. To apply the fabrication method of the SiO₂ layer for universal support materials, which are not specifically designed as a photocatalyst, precise control of the pH of the SiO₂ deposition solution is very crucial for effective SiO₂ decoration on Pd nanoparticles.

Experimental

Materials

All chemicals were used as received. Rutile TiO₂ (<5 μm, ≥99.9%), tetramethylammonium bromide (TMAB, ≥98.0%), NaNO₃ (≥99.0%), sodium hydroxide (NaOH, 99.9%), hydrochloric acid (HCl, 37%), methanol (99.5%), and ethanol (99.5%) were purchased from Sigma–Aldrich. HNO₃ solution containing

Pd(NO₃)₂ (0.216 M) was purchased from Kojima Chemicals Co., Ltd. Tetraethyl orthosilicate (TEOS, >97.0%) was purchased from Tokyo Chemical Industry.

Preparation of Pd-impregnated TiO₂

The Pd/TiO₂ catalyst was prepared by a simple impregnation method. TiO₂ rutile (0.950 g) was dispersed in a mixture of ultrapure water (20 mL) and Pd(NO₃)₂·HNO₃ solution (0.202 or 1.01 mL corresponding to 1 or 5 wt% Pd). The resulting slurry was ultrasonicated for 15 min and stirred while heating in a water bath at 100 °C until the water completely evaporated. Next, the sample was placed in a muffle furnace and calcined under static air for 2 h at 500 °C, 700 °C, or 900 °C with a heating rate of 5 °C min⁻¹. Finally, the products were reduced under pure H₂ for 2 h at 150 °C with a heating rate of 5 °C min⁻¹.^{36–38} The obtained catalysts were denoted as Pd/TiO₂-500, Pd/TiO₂-700, and Pd/TiO₂-900, respectively.

Photocatalytic performance test of Pd/TiO₂

A photocatalytic performance test was conducted on the 5 wt% Pd/TiO₂ catalyst to see whether the excited electrons from TiO₂ could be utilized in this reaction. The Pd/TiO₂ catalyst (0.010 g) was dispersed in 10 mL of an aqueous solution of 10 vol% MeOH. The slurry was then irradiated with UV light under ambient pressure with stirring. The amount of evolved H₂ gas was quantified using an online GC (GC-8A, Shimadzu) equipped with a thermal conductivity detector (TCD). The apparent quantum yield (AQY) of the catalyst was calculated using the following equation:

$$\text{AQY} = 2 \times \frac{N(\text{H}_2)}{N(\text{photons})}$$

where $N(\text{H}_2)$ and $N(\text{photons})$ denote the number of H₂ molecules produced and the number of photons reaching the surface of the reaction solution, respectively.

SiO₂ precipitation by increasing pH

A solution was prepared for the SiO₂ precipitation test by dissolving TMAB (5.25 g) and NaNO₃ (0.852 g) in a mixture of ultrapure water (100 mL) and ethanol (100 mL). TEOS (15.2 mL) was then added into the solution after the pH was adjusted to 3 with HCl (1.0 M). After 2 h of stirring, NaOH aqueous solution (10 mM) was added drop by drop to increase the pH. With every increase in pH of 0.5, the UV-Vis absorption spectrum and dynamic light scattering (DLS) of the solution were measured using a JASCO UV-Vis V-770 (wavelength range of 200 nm to 2700 nm with a scan speed of 400 nm min⁻¹) and HORIBA nanoPartica SZ-100, respectively. For the DLS measurement, the diameter of the precipitates was determined from the average of 10 measurements.

Preparation of the Pd@SiO₂/TiO₂ structure

SiO₂ layer deposition on Pd/TiO₂ was performed in a solution consisting of TMAB, NaNO₃, and TEOS. TMAB (7.86 g) and NaNO₃ (1.28 g) were dissolved in a mixture of ultrapure water



(150 mL) and ethanol (150 mL), and then TEOS (22.8 mL) was added to the solution after the pH was adjusted to 3 with HCl (1.0 M). After 2 h of stirring, Pd/TiO₂-500 (0.150 g) was dispersed in the solution, and the pH was adjusted to 5 by the addition of an aqueous solution of NaOH (0.10 M). The resulting slurry was irradiated with UV light (Asahi Spectra Co., Ltd., CL-H1-365-9-1) for 0.5 h with stirring and Ar bubbling. The UV light had a peak wavelength of 370 nm and a power of 870 mW.

The precipitates were separated by centrifugation and dried for 16 h at 110 °C with a heating rate of 5 °C min⁻¹. They were then calcined under static air for 2 h at 500 °C, 700 °C, or 900 °C with a heating rate of 5 °C min⁻¹ in a muffle furnace. Finally, the catalysts were reduced under 30 mL min⁻¹ of pure H₂ for 2 h at 150 °C with a heating rate of 5 °C min⁻¹. They were denoted as Pd@SiO₂/TiO₂-500, Pd@SiO₂/TiO₂-700, or Pd@SiO₂/TiO₂-900, respectively.

Carbon monoxide chemisorption

The obtained catalysts (0.040 g) were packed in a U-shape quartz tube and pretreated under 4% H₂ balanced with Ar (10 mL min⁻¹) at 150 °C for 30 min with a heating rate of 40 °C min⁻¹. After purging with pure Ar (10 mL min⁻¹) at 150 °C for 30 min, the catalysts were cooled down to 10 °C with ice packs. Subsequently, 500 μL of diluted CO gas (Ar balance, 0.4%) was injected every 8 min until CO was no longer adsorbed. The amount of CO that slipped through without being adsorbed was quantified using a gas chromatograph with a flame ionization detector (SHIMADZU GC-FID, GC-8A) and a methanizer (SHIMADZU MTN-1) and calculated from the peak area.

Characterization

Transmission electron microscope (TEM) images were obtained using a JEOL 2000EX-II (acceleration voltage: 200 kV) equipped with a CCD camera. The specimens for TEM were prepared by placing drops of the sample dispersed in EtOH onto a 200-mesh copper grid coated with an amorphous carbon film with holes. Scanning transmission electron microscope images and energy dispersive spectroscopy mappings (STEM/EDS) were obtained using an FEI Talos F200X equipped with a Super-X (FEI) and SDD detector (Bruker). Nitrogen adsorption-desorption isotherms were recorded using a MicrotracBEL BELMETAL III. Prior to the measurement, the samples were dried under vacuum at 100 °C for 2 h.

Elemental analysis of the catalysts was performed using a scanning electron microscope and an energy dispersive X-ray spectrometer (SEM/EDX, Hitachi High-Tech S-4700-D). The length of the measurement was 120 s, and the acceleration voltage was 20.00 kV. Inductively coupled plasma optical emission spectrometry measurements were also performed (ICP-OES, Agilent 5110 VDV). X-ray photoelectron spectroscopy (XPS) was performed using a JEOL JPS-9010 MC with a Mg K α X-ray source. The powder sample was deposited on a metal nickel plate, and powder X-ray diffraction (XRD) patterns of the catalysts were collected on a D/texUltra UltimaIII operated at 40 kV and 40 mA. The samples were scanned from 20° to 60° at 10° min⁻¹, and the average of 10 measurements was taken.

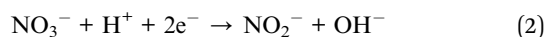
Catalytic performance test

Catalytic reaction rates were measured using a fixed bed catalyst reactor system (MicrotracBEL, BELREA). First, 0.100 g of each catalyst was pretreated at 500 °C in both O₂ flow and H₂ flow for 15 min each. The catalytic performance was then tested in 400 mL min⁻¹ of simulated exhaust gas, which consisted of 500 ppm of NO, 5000 ppm of CO, 400 ppm of C₃H₆, 10% H₂O, 14% CO₂, 4900 ppm of O₂, and 1700 ppm of H₂ in N₂ balance and ambient pressure. The reaction temperature was 200 °C to 500 °C. The outlet gas was analyzed by FT-IR (Best Instruments Co., Ltd., Bex-1000FT), an oxygen meter, and a hydrogen meter (Best Instruments Co., Ltd., Bex-520M).

Results and discussion

Photocatalytic shell formation scheme

Fig. 1 illustrates the shell formation scheme. Under UV light irradiation, the electrons generated by the photoexcitation of TiO₂ can be transferred to Pd nanoparticles. Next, the excited electrons in the Pd nanoparticles produce H₂ or reduce NO₃⁻ as in the following equations, resulting in higher local pH in the vicinity of the Pd nanoparticles.



The locally increased pH induces the polymerization reaction of TEOS to form Si_xO_y oligomers, which are deposited on the Pd surface with TMA⁺ by electrostatic force.³⁹⁻⁴¹ Finally, the removal of TMA⁺ by the calcination process forms micropores in the SiO₂ shell, which allows gas diffusion to the core Pd.^{42,43}

Optimization of SiO₂ decoration conditions

The photocatalytic activity of 5 wt% Pd/TiO₂ is shown in Fig. S1,† for which the H₂ production rate was recorded in the presence of methanol as an electron donor. The 5 wt% Pd/TiO₂ catalyst (~0.6%) had an apparent quantum yield (AQY) at

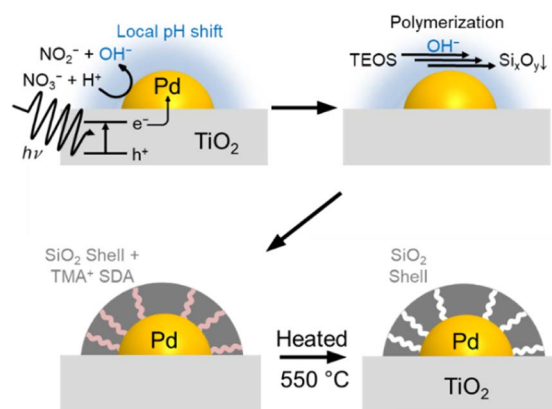


Fig. 1 Scheme of SiO₂ shell formation on supported Pd nanoparticles under UV light irradiation.



370 nm that was approximately one-hundredth lower than the reported AQY value for SrTiO₃-based photocatalysts.³⁹ Hence, the local pH shift induced by the photocatalysis of 5 wt% Pd/TiO₂ was expected to be smaller than that of Pt/SrTiO₃. Therefore, prior to the preparation of the catalyst, the threshold pH for SiO₂ precipitation was precisely measured. Based on the results, the initial pH for SiO₂ decoration on Pd/TiO₂ was determined to be slightly lower than the threshold pH.

Fig. 2a shows the UV-Vis transmission spectra of the solutions consisting of TEOS, NaNO₃, and TMAB at various pH controlled by the addition of aqueous NaOH solution. The transmittance is hardly changed in the range of pH 3.5–5.5, but it begins to decrease slightly at pH 6.0 and significantly drops at pH 6.4. These results demonstrate that a small amount of Si_xO_y nanoparticles were formed at pH 6.0, and more were produced at pH 6.4. The formation of the nanoparticles was also observed by DLS measurements, as shown in Fig. 2b.

Below pH 6, almost no particles were present in the solution, which is consistent with the non-reproducible histograms derived from small fluctuations of the laser. Particles with a size distribution of 20–100 nm were observed at pH 6.0, which increased to 100–300 nm at pH 6.4. These results suggest that the formation of Si_xO_y precipitates by dehydration condensation of TEOS-derived Si(OH)₄ began at pH 5.5–6.0. Based on the results, the initial pH of the solution for SiO₂ deposition was set to 5.

SiO₂ shell decoration on Pd/TiO₂

Fig. 3 shows the TEM images of the 5 wt% Pd/TiO₂-500, 5 wt% Pd/TiO₂-900, 5 wt% Pd@SiO₂/TiO₂-500, and 5 wt% Pd@SiO₂/TiO₂-900 catalysts. Pd nanoparticles with a size of about 5–

30 nm are observed in 5 wt% Pd/TiO₂-500 (Fig. 3a), but after 900 °C heat treatment in air, the Pd nanoparticles are sintered and have a particle size of more than 100 nm air (5 wt% Pd/TiO₂-900, Fig. 3b). Histograms of Pd particle size on 5 wt% Pd/TiO₂-500 and 5 wt% Pd/TiO₂-900 obtained from TEM images are shown in Fig. 3k. The mean particle size increased from 16 nm to over 130 nm. The distribution of Pd particle size was statistically enlarged due to sintering induced by high-temperature heat treatment. The TEM image of 5 wt% Pd@SiO₂/TiO₂-500 in Fig. 3c shows that Pd nanoparticles with a size of ~40 nm are covered by an amorphous shell with a thickness of ~15 nm. Other TEM images of 5 wt% Pd@SiO₂/TiO₂-500 are shown in Fig. S2.† The particle size of Pd nanoparticles was roughly ~20 nm and the thickness of the SiO₂ layer was ~20 nm.

To confirm that the amorphous shell consists of SiO₂, STEM/EDS mapping images of Pd and Si distribution on the catalysts were acquired (Fig. 3e–g). The distribution of Si is localized around the Pd nanoparticles in both 5 wt% Pd@SiO₂/TiO₂-500 and 5 wt% Pd@SiO₂/TiO₂-900, demonstrating that the amorphous shell layer on Pd nanoparticles in Fig. 3c should be SiO₂. Similar to the 5 wt% Pd/TiO₂, SiO₂ decoration on 1 wt% Pd/TiO₂ was also demonstrated, as shown in Fig. S3.† The Pd nanoparticles with a size of about 5 nm were covered by amorphous SiO₂ shells with a thickness of a few nanometers. Fig. S4† shows the SEM image of 5 wt% Pd@SiO₂/TiO₂-500. The particle size of the TiO₂ was ~1 μm.

To investigate the importance of UV light irradiation for uniform decoration of the SiO₂ shell on Pd nanoparticles, TEOS treatment of Pd/TiO₂ catalysts under dark conditions was performed as a control experiment. The TEM image of the Pd/TiO₂ after TEOS treatment under dark conditions (Fig. S5†) shows sparse deposition of amorphous SiO₂ clusters on the entire Pd/TiO₂ surface. Unlike Pd@SiO₂/TiO₂ catalysts prepared by UV-light irradiation, the Pd nanoparticles were not covered by the uniformly decorated SiO₂ nanoparticles. Therefore, the photocatalytic reaction induced by UV light irradiation is essential for the uniform SiO₂ shell decoration on Pd nanoparticles.

Weight fractions of Si and Pd in 5 wt% Pd@SiO₂/TiO₂-500 were determined by ICP-OES measurement and the results are shown in Table 1. The weight percent of Pd was measured to be 5.0 wt%, which is equal to the Pd quantity in the impregnation solution. The weight fraction of SiO₂ was determined to be 5.9 wt%. No impurities of Na and Br were detected. According to the density of the Pd and SiO₂ (12.0 g cm⁻³ and 2.65 g cm⁻³, respectively), the volume ratio between the Pd and SiO₂ was calculated as 1:5.3.

Assuming that all the SiO₂ forms a hemispherical shell on the hemispherical Pd nanoparticles, the thickness of the shell should be about 0.4 times the diameter of the Pd nanoparticles. Hence, if the Pd grain size is 40 nm, the thickness of the SiO₂ shell is calculated to be 16 nm, which is roughly consistent with the TEM result (Fig. 3c). Therefore, the weight content of the SiO₂ (~6 wt%) should be reasonable. SiO₂ particles were also observed on the TiO₂ surface because SiO₂ precursors are unavoidably adsorbed on the TiO₂ surface.

The Pd particle size is almost maintained even after heat treatment at 900 °C in air (5 wt% Pd@SiO₂/TiO₂-900, Fig. 3d).

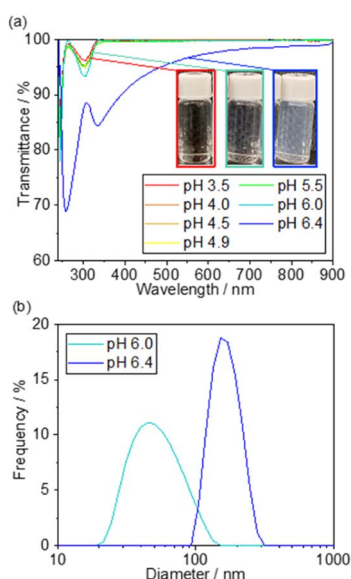


Fig. 2 SiO₂ precipitation test results. (a) UV-Vis transmission spectra of the solutions consisting of TEOS, NaNO₃, and TMAB at various pH controlled by the addition of aqueous NaOH solution. (b) The particle size distribution of the precipitates in the solution at pH 6.0 and 6.4 obtained by DLS measurement.



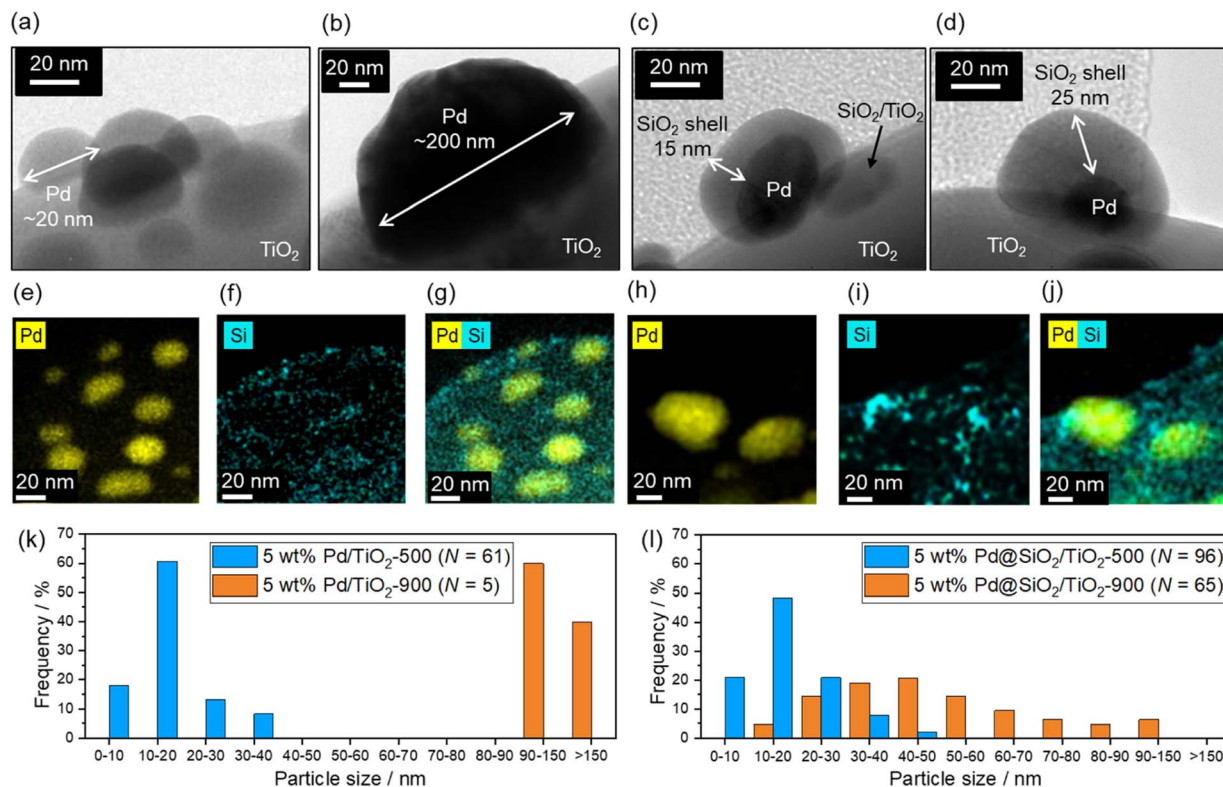


Fig. 3 TEM images of (a) 5 wt% Pd/TiO₂-500, (b) 5 wt% Pd/TiO₂-900, (c) 5 wt% Pd@SiO₂/TiO₂-500, and (d) 5 wt% Pd@SiO₂/TiO₂-900, respectively. STEM/EDS mapping images of (e–g) 5 wt% Pd@SiO₂/TiO₂-500 and (h–j) 5 wt% Pd@SiO₂/TiO₂-900. Histogram of Pd particle size on (k) 5 wt% Pd/TiO₂-500 and 5 wt% Pd/TiO₂-900 obtained from TEM images, and (l) 5 wt% Pd@SiO₂/TiO₂-500 and 5 wt% Pd@SiO₂/TiO₂-900 obtained from STEM/EDS mappings.

Table 1 ICP results of 5 wt% Pd@SiO₂/TiO₂-500 and 5 wt% Pd@SiO₂/TiO₂-900

Sample	Component ratio/wt%			
	Pd	SiO ₂	TiO ₂	Si/Pd ratio
5 wt% Pd@SiO ₂ /TiO ₂ -500	5.0	5.9	89	2.1
5 wt% Pd@SiO ₂ /TiO ₂ -900	5.1	6.3	89	2.2

The diameter of the Pd nanoparticles seems to be slightly increased after heat treatment at 900 °C (Fig. 3h) in comparison to the STEM/EDS mapping images of Pd in 5 wt% Pd@SiO₂/TiO₂-500 (Fig. 3e). Histograms of Pd particle size on 5 wt% Pd@SiO₂/TiO₂-500 and 5 wt% Pd@SiO₂/TiO₂-900 were obtained from the STEM/EDS mapping and shown in Fig. 3l. Although the mean particle size increased from 23 nm to 53 nm after 900 °C heat treatment, the Pd particle size of 5 wt% Pd@SiO₂/TiO₂-900 was clearly statistically smaller compared to 5 wt% Pd/TiO₂-900. The localization of the Si distribution around Pd particles was also measured (Fig. 3i and j), and the weight percent of Pd and SiO₂ was not changed after heat treatment at 900 °C in air (Table 1). This suggests that the SiO₂ shell prevents aggregation of the Pd nanoparticles.

Table 2 summarizes the amount of CO adsorbed on 5 wt% Pd/TiO₂ and 5 wt% Pd@SiO₂/TiO₂ after heat treatment in air at various temperatures. The amount of CO adsorbed on 5 wt%

Pd/TiO₂ after heat treatment at 500 °C drastically dropped from 15 μmol g_{cat}⁻¹ to 2.8 μmol g_{cat}⁻¹ after heat treatment at 900 °C. The rate of the decrease of the surface Pd site after heat treatment at 900 °C in air was calculated to be 22%. The calculated particle diameter with an assumption of hemispherical Pd particles was 25 nm after heat treatment at 500 °C and 139 nm after heat treatment at 900 °C, which is consistent with the TEM results.

The CO adsorption capacity on 5 wt% Pd@SiO₂/TiO₂ was 94% retained even after heat treatment at 900 °C, suggesting that the SiO₂ decoration suppressed the aggregation of Pd nanoparticles and achieved excellent high-temperature stability. Although the CO adsorption amount decreases for

Table 2 Results of CO chemisorption capacity (unit: μmol g_{cat}⁻¹)

Sample	Heat treatment temperature			Rate of decrease by 900 °C heating
	500 °C	700 °C	900 °C	
5 wt% Pd/TiO ₂	15	13	2.8	19%
5 wt% Pd@SiO ₂ /TiO ₂	5.0	5.2	4.7	94%
1 wt% Pd/TiO ₂	5.4	n.t. ^a	1.2	22%
1 wt% Pd@SiO ₂ /TiO ₂	1.7	n.t. ^a	1.7	100%

^a Not tested.



5 wt% Pd@SiO₂/TiO₂-500 (5.0 μmol g_{cat}⁻¹) compared to 5 wt% Pd/TiO₂-500 (15 μmol g_{cat}⁻¹), this result may not simply be due to the SiO₂ layer inhibiting the adsorption of CO onto the Pd surface. As will be discussed later, the catalytic activity of exhaust gas purification reactions is almost unchanged with or without the SiO₂ layer. Hence, it can be concluded that SiO₂ does not block the surface sites, and the decrease in CO adsorption by the SiO₂ layer modification can be attributed to the difference in the interaction between CO and the Pd surface.

A similar trend was observed when the loaded Pd amount was decreased to 1 wt%. The amount of CO adsorbed on 1 wt% Pd/TiO₂ significantly drops to 22% after heat treatment at 900 °C in air, but the CO adsorption amount on 1 wt% Pd@SiO₂/TiO₂ is well maintained (~100%) after the heat treatment. Therefore, aggregation of Pd nanoparticles at elevated temperature can be effectively prevented by the shell.

X-ray photoemission spectroscopy was also performed on 5 wt% Pd/TiO₂-500 and 5 wt% Pd@SiO₂/TiO₂-500. In the survey scan (Fig. 4a), Si peaks that cannot be seen for 5 wt% Pd/SiO₂/TiO₂-500 clearly appear for 5 wt% Pd@SiO₂/TiO₂-500, indicating that SiO₂ was deposited on the catalyst. The detailed chemical state of Si species on the Pd/TiO₂ catalyst was characterized using the Si 2p region X-ray photoemission spectrum (Fig. 4b). Based on the binding energy of the Si 2p peaks, the deposited Si species on both Pd@SiO₂/TiO₂ and Pd/TiO₂ after TEOS treatment under dark conditions can be identified as SiO₂. The spectra show that the Si 2p peak position of Pd@SiO₂/TiO₂ was positively shifted compared to the Si 2p peak of the Pd/TiO₂ catalyst after TEOS treatment under dark conditions. Unlike the SiO₂ clusters sparsely deposited on the Pd/TiO₂ catalyst, the SiO₂ shell localized on the Pd nanoparticles became positively charged probably due to electron withdrawal by Pd nanoparticles.

Fig. 4c shows the detailed spectra of the region of Pd 3d peaks. The peak area decreased after the SiO₂ decoration, suggesting that the Pd nanoparticles were successfully covered by SiO₂. Pd 3d peaks were also slightly decreased by the TEOS treatment, suggesting that the Pd nanoparticles should be

partially coated with the SiO₂ clusters. However, the peak intensity is much higher than that of the Pd@SiO₂/TiO₂ catalysts prepared by UV light irradiation. Therefore, the photocatalytic reaction triggers uniform SiO₂ shell formation on Pd nanoparticles, which corresponds to the TEM observation.

Deconvolution revealed the components of metallic Pd (340.5 eV and 335.3 eV) and PdO (342.3 eV and 337.0 eV) in the spectra of both 5 wt% Pd/TiO₂-500 and 5 wt% Pd@SiO₂/TiO₂-500. The ratio of the PdO peak to the Pd metal peak is higher for 5 wt% Pd@SiO₂/TiO₂-500, which is probably due to the selective SiO₂ decoration on metallic Pd or oxidation of the surface Pd species resulting from the formation of an interface with the SiO₂ shell.

The surface area and porosity of the SiO₂ shell were examined using nitrogen adsorption–desorption isotherms and carbon monoxide pulsed adsorption measurement, as shown in Fig. 5. The isotherm of 5 wt% Pd/TiO₂-500 exhibits type II features and a Brunauer–Emmett–Teller (BET) surface area of 4.5 m² g_{cat}⁻¹ (Fig. 5). However, the isotherm of 5 wt% Pd@SiO₂/TiO₂ shows a steep rise in the lower relative pressure region, suggesting the presence of micropores. The BET surface area of Pd@SiO₂/TiO₂ was 45 m² g_{cat}⁻¹. The 10-fold increase in the surface area of 5 wt% Pd@SiO₂/TiO₂ compared to Pd/TiO₂ is attributed to the porous nature of the SiO₂ shell on Pd.

Fig. 6 shows the XRD patterns of 5 wt% Pd/TiO₂ and 5 wt% Pd@SiO₂/TiO₂ after heating at various temperatures. All patterns exhibited a small peak around 40.1° corresponding to Pd⁰(111). The pattern of 5 wt% Pd/TiO₂ demonstrated that the TiO₂ support consisted of a major rutile phase and a minor anatase phase. The minor anatase peaks of 5 wt% Pd/TiO₂ disappeared after heat treatment at 900 °C. Typically, the transition temperature of TiO₂ without any modifications is around 800 °C. However, 5 wt% Pd@SiO₂/TiO₂ showed the anatase peaks even after heat treatment at 900 °C, suggesting that SiO₂ deposition on the Pd/TiO₂ shifted the anatase-to-rutile transition temperature of the TiO₂ support to a higher temperature.

Okada *et al.* reported an upper shift of the transition temperature of TiO₂ by a few atomic percent with Si doping. This was due to the suppression of surface nucleation sites for rutile by the formation of an amorphous SiO₂ surface layer.⁴⁴ Similar to this report, the SiO₂ partially covering the Pd/TiO₂

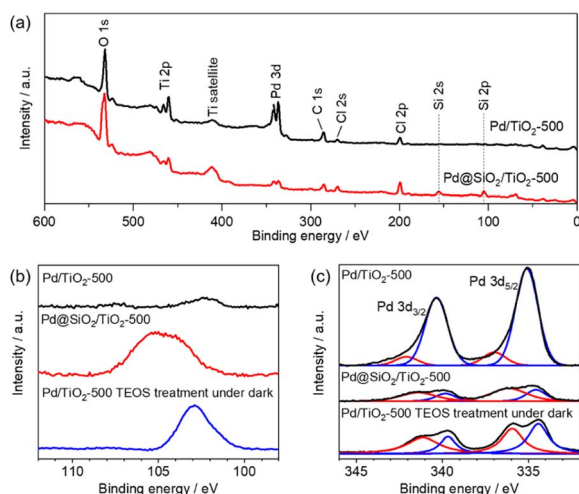


Fig. 4 XPS results of 5 wt% Pd/TiO₂-500 and 5 wt% Pd@SiO₂/TiO₂-500. (a) Survey scan, (b) Si 2p region and (c) Pd 3d region.

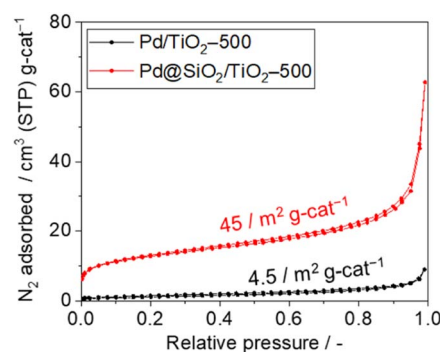


Fig. 5 Nitrogen adsorption–desorption isotherms of 5 wt% Pd/TiO₂-500 and 5 wt% Pd@SiO₂/TiO₂-500.



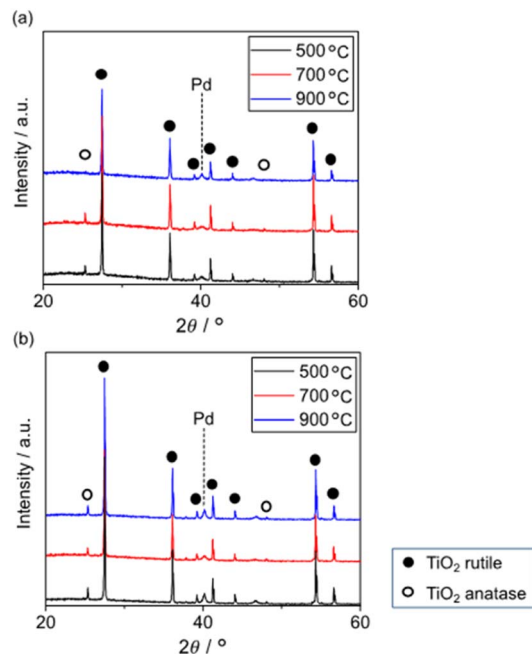


Fig. 6 XRD patterns of (a) 5 wt% Pd/TiO₂-500, 700, 900 and (b) 5 wt% Pd@SiO₂/TiO₂-500, 700, 900.

applied *via* photodeposition seemed to have the ability to suppress the nucleation sites of rutile TiO₂.

Catalytic performance of Pd@SiO₂/TiO₂

The purification reaction of simulated exhaust gas was examined to investigate the influence of the high-temperature

treatment of 5 wt% Pd/TiO₂ and 5 wt% Pd@SiO₂/TiO₂ on the catalytic performance (Fig. 7). The test was carried out under a gas flow of NO (500 ppm), CO (5000 ppm), C₃H₆ (400 ppm), H₂O (10%), CO₂ (14%), O₂ (4900 ppm), and H₂ (1700 ppm) with N₂ balance at ambient pressure. The conversion of NO reduction, CO oxidation, and C₃H₆ oxidation was estimated from the concentrations of NO, CO, and C₃H₆ in outlet gas, respectively, while N₂ reduction was estimated using the NH₃, NO₂, and N₂O concentrations in the outlet gas.

In all reactions, the conversion increased at an elevated reaction temperature, but there was a relatively high conversion of NO and N₂ reduction at lower temperature due to the selective reduction by H₂ contained in the reaction gas. In other words, the reducing agent for NO and N₂ reduction was changed from H₂ at lower temperature to other gases (*e.g.*, CO or C₃H₈) at higher temperature. This occurred because the H₂ was consumed by the reaction with O₂ at higher temperature.⁴⁵

The conversion of NO reduction, N₂ reduction, and C₃H₈ oxidation over 5 wt% Pd/TiO₂ significantly dropped after heat treatment at 900 °C in air due to the aggregation of the Pd nanoparticles. In contrast, Pd@SiO₂/TiO₂ maintained the conversion of the NO and N₂ reduction or improved the conversion of C₃H₈ oxidation even after the treatment. This demonstrates the protective role of the SiO₂ shell on Pd nanoparticles in preventing the thermal drop of the catalytic performance. The catalytic performance of Pd@SiO₂/TiO₂-500 for the NO reduction, N₂ reduction and C₃H₈ oxidation was almost corresponding to the performance of Pd/TiO₂-500. Therefore, the gas permeability of the SiO₂ shell was sufficiently high not to prevent the catalytic reaction at Pd nanoparticles. Moreover, SiO₂ decoration does not inhibit the Pd surface site

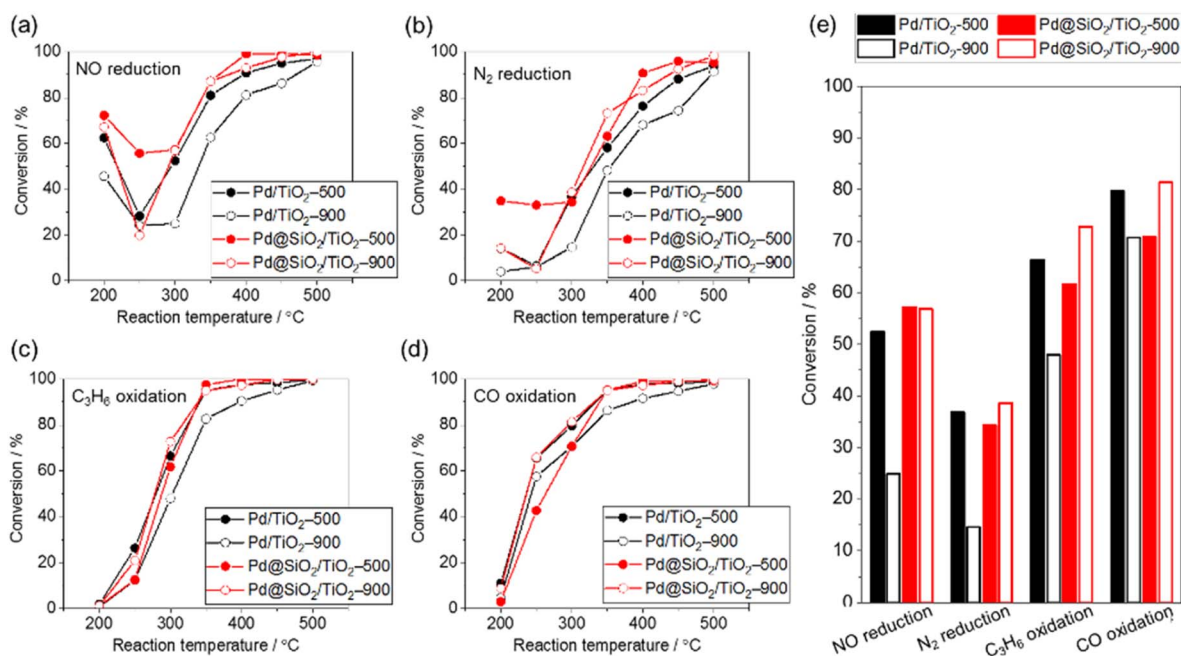


Fig. 7 Catalytic performance in simulated exhaust gas (500 ppm NO, 5000 ppm CO, 400 ppm C₃H₆, 10% H₂O, 14% CO₂, 4900 ppm O₂, and 1700 ppm H₂ in N₂ balance, 400 mL min⁻¹, ambient pressure). (a) NO reduction, (b) N₂ reduction, (c) hydrocarbon oxidation, (d) CO oxidation, and (e) summarized bar graph at 300 °C.



for activation of exhaust gas. On the other hand, the performance of CO oxidation is not significantly changed by the SiO₂ decoration and probably due to CO diffusion limitation of the CO oxidation kinetics above 277 °C.⁴⁶

There have been no previous demonstrations of the use of these photocatalytically fabricated gas-permeable layers for high-temperature thermal catalytic reactions, and this paper is the first report of such a demonstration. The current photocatalytic fabrication method can be applied for a large variety of gas permeable layers, such as chromium-,⁴⁷ molybdenum-,⁴⁸ titanium-,^{49,50} tantalum-based oxides,^{49,50} and so on. Furthermore, this photo-assisted fabrication method does not require special vacuum conditions and can be applied for mass production using a continuous-flow synthesis system.⁵¹ This study bridges strategies of photocatalysis-assisted nanostructure synthesis and thermal catalysts with sintering tolerance.

Conclusions

In this work, ultrathin SiO₂ shells were successfully synthesized on Pd nanoparticles supported by TiO₂ by a local pH shift near the supported Pd catalyst using a UV light-induced photocatalytic reaction on the TiO₂ support. TEM and STEM/EDS mapping images showed that the particle size of the Pd nanoparticles (~40 nm) with the SiO₂ shell (~20 nm) was almost unchanged by high-temperature treatment at 900 °C in air. This suggested that the SiO₂ shell prevented thermal aggregation of the nanoparticles. The Pd/TiO₂ without the SiO₂ shell exhibited a drop in the number of active sites, which was likely due to aggregation of the -Pd catalysts. However, the number of active sites on the Pd@SiO₂/TiO₂ catalyst was maintained even after the catalyst was calcined at 900 °C. Consequently, the SiO₂ shell on Pd nanoparticles prevented the drop in the catalytic performance of the Pd/TiO₂ catalyst in simulated exhaust gas purification without disturbing the catalytic performance.

Author contributions

K. T. and H. M. led the research and contributed to the experiment planning, results analysis, and supervision of the research project. A. T. and H. T. carried out the experiments. F. K. and H. T. were involved in the design of experiments, results analysis, and paper writing. All the authors worked on the preparation of the manuscript and provided useful comments.

Conflicts of interest

There are no conflicts to declare.

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